| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|----------|---------|--|---|---------------------|---------|------------------|
| L1 | 11049 | ((438/42) or (438/221) or (438/225) or (438/296) or (438/297) or (438/298) or (438/359) or (438/362) or (438/400) or (438/423) or (438/424) or (438/425) or (438/434) or (438/439) or (438/434) or (438/439) or (438/440) or (438/449) or (438/447) or (438/449) or (438/450) or (438/452) or (438/524) or (438/546) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 17:18 |
| L2 | 441262 | ("438"/\$.ccls. or "257"/\$.ccls.) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:19 |
| L3 | 1042714 | "O.sub.2" or oxygen | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:20 |
| L4 | 1965663 | implant\$6 or dop\$3 or inject\$3 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:22 |
| L5 | 26997 | concentration\$1 with peak\$1 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:22 |
| L6 | 2164555 | (oxid\$5 or fox or (field near3 oxid\$5) or locos or (local near3 oxid\$5)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:23 |
| L7 | 47890 | 4 with 3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:24 |

| L8 | 1071 | 5 and 6 and 7 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:24 |
|-----|------|---------------------|---|----|-----|------------------|
| L9 | 76 | 1 and 8 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 18:04 |
| L10 | 551 | (257/E21.545).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 18:12 |
| L11 | 827 | (257/E21.552).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 18:15 |
| L12 | 9 | 5 and 11 | USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 18:16 |
| L13 | 38 | 7 and 11 | USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 18:21 |
| L14 | 595 | 438/439 | USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 18:21 |
| L15 | 228 | 438/440 | USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 18:22 |

| S1 | 7066 | ((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/423) or (438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/561) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/08/23 22:00 |
|----|-------|--|---|----|-----|------------------|
| S2 | 486 | implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:46 |
| S3 | 594 | (soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:46 |
| S4 | 16042 | locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 12:37 |
| S5 | 2 | (((implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and ((soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3))) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon))) and (((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/423) or (438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or (438/449) or (438/447) or (438/449) or (438/450) or (438/452) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS.) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:24 |
| S6 | 6 | ((implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and ((soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3))) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:24 |

| S7 | 14 | (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and ((soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:25 |
|-----|--------|---|---|----|-----|------------------|
| 58 | 6 | (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole)) and (((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/423) or (438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/561) or (438/766) or (438/769) or (438/770)). CCLS.) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:28 |
| S9 | 47 | implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:29 |
| S10 | 5 | ("4292091" "4319954" "4323417" "4338139" "4339285").PN. | USPAT | OR | OFF | 2004/08/12 14:31 |
| S11 | 20 | "4437225".URPN. | USPAT | OR | OFF | 2004/08/12 14:32 |
| S12 | 16 | ("4437225" "4683637" "4700454" "4810664" "5032535" "5114872" "5279978" "5418174" "5460983" "5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN. | USPAT | OR | OFF | 2004/08/12 14:35 |
| S13 | 11 | ("4437225" "4863878" "4948742" "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. | USPAT | OR | OFF | 2004/08/12 14:37 |
| S14 | 107731 | fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:49 |

| S15 | 11 | (((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/423) or (438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/564) or (438/561) or (438/566) or (438/766) or (438/769) or (438/770)).CCLS.) and ((implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:41 |
|-----|----|---|---|----|----|------------------|
| S16 | 62 | (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:54 |
| S17 | 51 | ((implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon))) not ((((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/423) or (438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/561) or (438/566) or (438/567) or (438/561) or (438/766) or (438/769) or (438/770)). CCLS.) and ((implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon)))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:44 |
| S18 | 5 | (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) same (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:53 |

| S19 | 12 | ((implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) same oxidiz\$5) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:56 |
|-----|--------|--|---|----|-----|------------------|
| S20 | 59 | (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) same oxidiz\$5 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 14:56 |
| S21 | 486 | implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 16:26 |
| S22 | 594 | (soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 16:27 |
| S23 | 107731 | fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 21:17 |
| S24 | 0 | (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) same ((soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 16:58 |
| S25 | 14 | (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) and ((soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 16:28 |
| S26 | 6 | ("5955767" "6100159" "6174754" "6403433" "6501133" "6515333"). PN. | USPAT | OR | OFF | 2004/08/12 16:32 |
| S27 | 0 | "6724049".URPN. | USPAT | OR | OFF | 2004/08/12 16:33 |
| S28 | 1 | "6501133".URPN. | USPAT | OR | OFF | 2004/08/12 16:34 |
| S29 | 8 | ("5614729" "5920097" "5955767" "6100159" "6130457" "6174754" "6287901" "6303412").PN. | USPAT | OR | OFF | 2004/08/12 16:34 |

| | | | _ | | | |
|-----|--------|---|---|----|-----|------------------|
| S30 | 41 | ((soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3)) same (fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 16:58 |
| S31 | 107731 | fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 21:18 |
| S32 | 92 | (fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide)) near10 (sidewall\$1 near trench\$2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 21:45 |
| S33 | 18 | (fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide)) near10 ((etch\$3 near5 sidewall\$1) near3 trench\$2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 21:46 |
| S34 | 995 | oxide near2 (layer or film) same ((ion near2 implant\$4) near5 (oxygen near ion)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 15:37 |
| S35 | 16042 | locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON- | 2004/08/13 12:37 |
| S36 | 15 | (oxide near2 (layer or film) same ((ion near2 implant\$4) near5 (oxygen near ion))) same (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 12:37 |
| S37 | 325 | oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 15:36 |
| 538 | 49 | (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) and (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 12:44 |

| S39 | 8 | (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) same (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 12:44 |
|-----|-----|--|---|----|----|------------------|
| S40 | 41 | ((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) and (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)))) not ((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) same (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 15:33 |
| S41 | 276 | (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion))) not ((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) and (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 12:52 |
| S42 | 0 | ((oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion))) not ((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) and (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion))))) and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 12:52 |
| S43 | 41 | ((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) and (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)))) not ((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) same (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 15:34 |

| S44 | 74 | oxide near2 (layer or film)) same (((ion near2 implant\$4) near5 (oxygen near ion)) same (through near5 (oxide near2 (layer or film))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/13 15:40 |
|-----|---------|--|---|----|------|------------------|
| S45 | 2 | ("5372950" "5972777").PN. | USPAT | OR | OFF | 2004/08/16 10:57 |
| S46 | 2345371 | v | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/08/12 16:26 |
| S47 | 7514 | ((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/423) or (438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/546) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/05/13 14:45 |
| S48 | 23 | S47 and (soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:55 |
| S49 | 4 | S48 and (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/08/23 21:58 |
| S50 | 19 | S48 not S49 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON · | 2005/05/13 14:47 |
| S51 | 84 | S47 and (implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:49 |
| S52 | 31 | S51 and (fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:53 |

| S53 | 331 | (fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide)) near (silicon near (layer\$1 or film\$1)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:54 |
|-----|-----|--|---|----|-----|------------------|
| S54 | 58 | S53 and (soi or (silicon near2 insulator)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/05/13 14:55 |
| S55 | 6 | ("5863823" "5946595" "5965917" "5994191" "6015752" "6165903"). PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/05/13 14:57 |
| S56 | 48 | ("3562425" "3699544" "3829743" "3829881" "4037140" "4065781" "4177084" "4183134" "4198649" "4282556" "4385937" "4418470" "4420743" "4425700" "4463492" "4509990" "4523963" "4549198" "4588447" "4598305" "4607176" "4615762" "4617066" "4659392" "4717836" "4766482" "4775641" "4843442" "4843448" "4851721" "4872010" "4876582" "4907041" "4989057" "5027171" "5141882" "5166767" "5170373" "5196802" "5229644" "5242849" "5294823" "5300443" "5313077" "5341009" "5391903" "5416043" "5445802"). PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/05/13 14:58 |
| S57 | 3 | ("20010005030" "5279978" "5463238").PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/05/13 15:05 |
| S58 | 6 | ("5145802" "5151381" "5334550" "5358890" "5374586" "5422287"). PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/05/13 15:09 |
| S59 | 8 | ("3690968" "3974515" "4729006" "4983535" "5060035" "5340999" "5381029").PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/05/13 15:12 |
| S60 | 951 | ((implant\$4 or dop\$3) near5 (oxygen near2 ion\$1)) near10 (oxide or (pad near2 oxide)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/31 14:07 |

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|-----|------|--|---|----|-----|------------------|
| S61 | 7596 | ((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/423) or (438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/546) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/01/31 13:59 |
| S62 | 104 | S60 and S61 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/08/23 22:02 |
| S63 | 97 | S62 and ((oxid\$5 or fox or (field near3 oxid\$5) or locos or (local near3 oxid\$5)) same silicon) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/08/23 22:24 |
| S64 | 5 | ("4683637" "5712173" "5976952" "6069054" "6258693").PN. | US-PGPUB; USPAT; USOCR | OR | ÖFF | 2005/08/23 22:14 |
| S65 | 3 | ("5393693" "5445989" "5498566"). PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/08/23 22:18 |
| S66 | 762 | S60 and ((oxid\$5 or fox or (field near3 oxid\$5) or locos or (local near3 oxid\$5)) same silicon) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/31 14:08 |
| S67 | 665 | S66 not S62 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/08/23 22:24 |
| S68 | 570 | S67 and (semiconductor) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/08/23 22:26 |
| S69 | 306 | S68 and (nitride) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/08/23 22:26 |

| | | <u> </u> | | 1 | 1 | |
|-----|-------|--|---|------|-----|--|
| S70 | 222 | S69 and (isolat\$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/08/23 22:26 |
| S71 | 1 | ("20050077580").PN. | US-PGPUB; USPAT | OR | OFF | 2005/09/13 19:54 |
| S72 | 1 | ("6489650").PN. | US-PGPUB; USPAT | OR | OFF | 2005/09/13 19:54 |
| S73 | 3 | ("5616942" "5831299" "5841185"). PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/09/13 19:55 |
| S74 | 3314 | (implant\$3 or inject\$3) near5 oxygen near5 (silicon or substrate) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/31 14:08 |
| S75 | 77832 | ("438"/\$.ccls. or "257"/\$.ccls.) and ((implant\$3 or inject\$3) near "5" oxygen naer5 through near5 (oxide or (pad adj oxide)) or (thermal adj oxide)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:19 |
| S76 | 2120 | S74 and S75 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR . | ON | 2005/09/14 15:17 |
| S77 | 11475 | ("438"/\$.ccls. or "257"/\$.ccls.) and ((implant\$3 or inject\$3) near5 oxygen near5 through near5 (oxide or (pad adj oxide)) or (thermal adj oxide)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/09/14 15:18 |
| S78 | 368 | S77 and S74 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/09/14 15:18 |
| S79 | 61 | S78 and (pad adj oxide) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/09/14 15:18 |

| S80 | 2 | ("4523213" "5712186").PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/09/14 15:43 |
|-----|---------|--|---|----|-----|------------------|
| S81 | 7 | ("5173444" "5229318" "5308787" "5399520" "5468657" "5470783" "5472906").PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/09/14 15:44 |
| S82 | 4 | ("4889829" "4929565" "5476809" "5547886").PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/09/14 15:46 |
| S83 | 6 | ("4437225" "4676841" "4725561" "4810664" "4835113" "4921812"). PN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2005/09/14 15:52 |
| S84 | 18 | ("5346841").URPN. | USPAT | OR | OFF | 2005/09/14 15:53 |
| S85 | 10506 | ((438/42) or (438/221) or (438/225) or (438/296) or (438/297) or (438/298) or (438/359) or (438/362) or (438/400) or (438/423) or (438/424) or (438/425) or (438/433) or (438/434) or (438/439) or (438/440) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/546) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/11/20 17:18 |
| S86 | 116 | S85 and ((implant\$4 or dop\$3) near5 (oxygen near2 ion\$1)) near10 (oxide or (pad near2 oxide)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/31 14:07 |
| S87 | 349 | S85 and (implant\$3 or inject\$3) near5 oxygen near5 (silicon or substrate) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/31 14:08 |
| S88 | 324 | S87 and (oxid\$5 or fox or (field near3 oxid\$5) or locos or (local near3 oxid\$5)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:23 |
| S89 | 1009683 | "O.sub.2" or oxygen | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:20 |

| S90 | 616603 | implant\$6 or dop\$3 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:21 |
|-----|---------|--|---|----|----|------------------|
| S91 | 25393 | concentration\$1 with peak | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/06/11 14:18 |
| S92 | 25395 | concentration\$1 with peak\$1 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/11/20 17:22 |
| S93 | 3219803 | "Si" or silicon or "SOI" or silicon\$1on\$1insulat\$3 or (silicon adj on adj insulat\$3) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/06/11 14:19 |
| S94 | 170 | S89 same S90 same S92 same S93 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/06/11 14:19 |